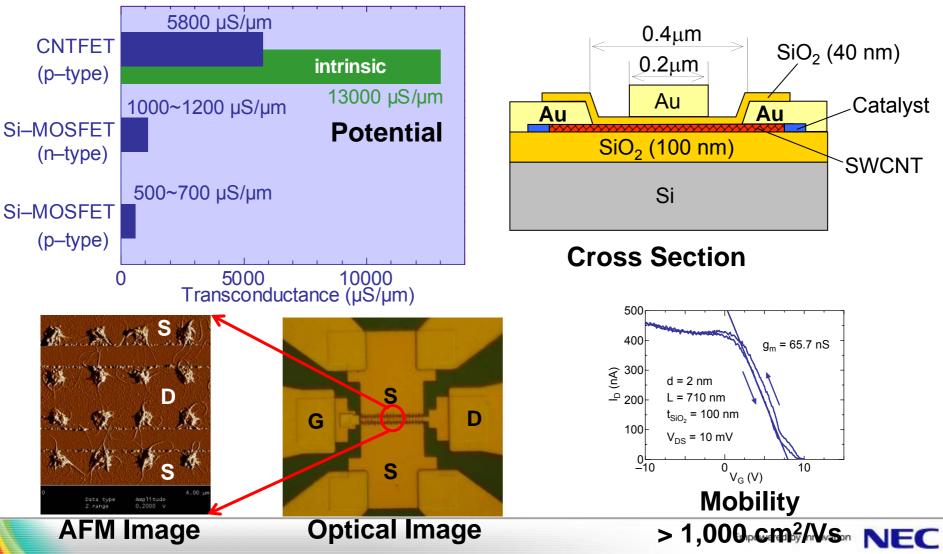
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Carbon nanotube thin film transistors on plastic films for printed electronics

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Carbon nanotube (CNT) transistor

Silicon-base CNT transistor shows very high electronical performance.

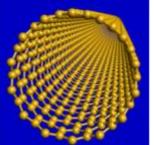


CNT for printed transistor

CNT has good features as a ink for printed electronics.

Structural characteristics

- Chemically stable
- Mechanically stable

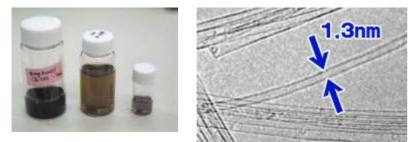


Electronic Characteristics

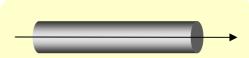
Large carrier mobility µ>1,000 cm²/Vs

Large current capacity

Handled in humid condition No degradation in solvent



Suitable for making ink



Ballistic conduction

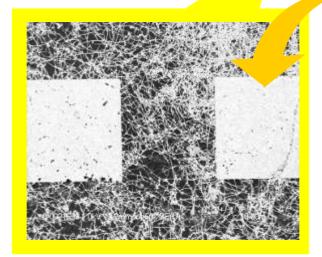
Organic : hopping conduction

High-speed operation



CNT transistor is fabricated by spin-coating "CNT ink" onto bendable plastic substrates.

CNT transistor on bendable plastic substrate



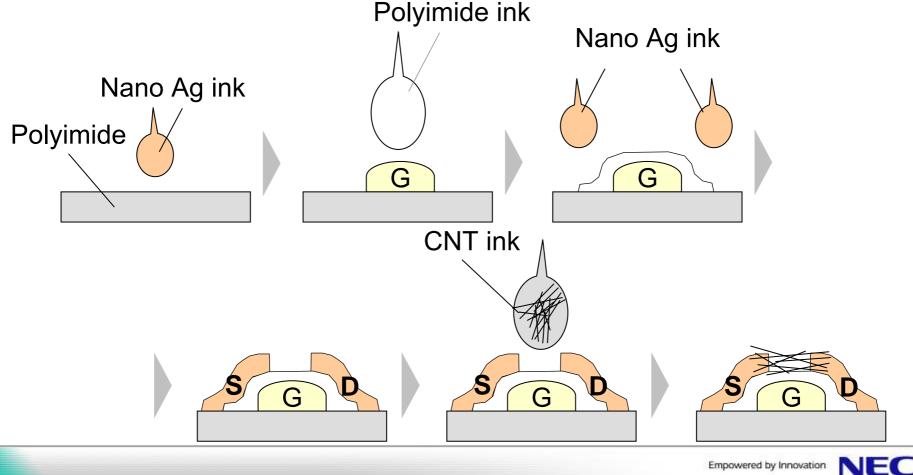
CNT Ink

CNT Transistor



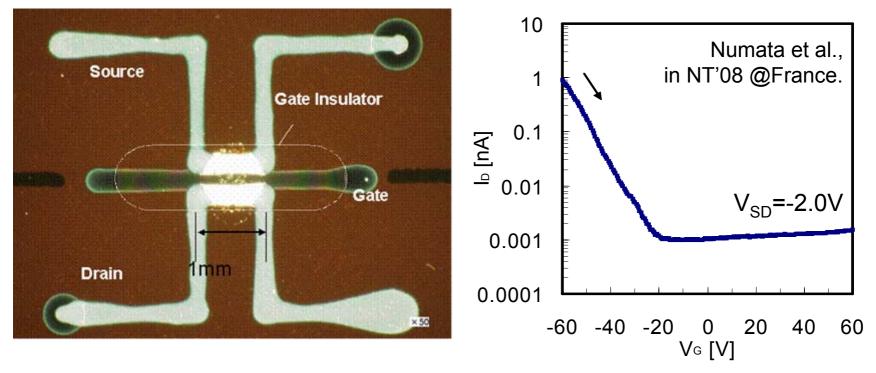
Fabrication process of the printed CNT transistor

- All parts of transistors (channel/insulator/electrodes) are printed.
 - Process temperatures are below 200°, applicable for plastic film



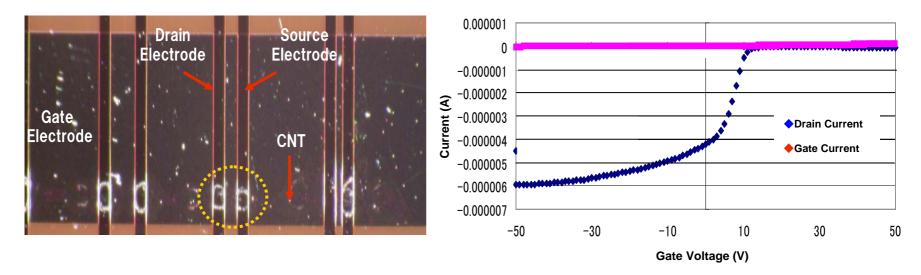
All printed CNT thin film transistor (TFT)

dispenser system for printing CNT pattern diameter was about 1mm Device properties: $\mu = 0.1 \text{ cm}^2/\text{Vs}$ and on/off ratio=1000



To improve the definition of the pattern, and increase CNT density, we applied to ink-jet printing method

Ink-jet printed CNT-TFT



ink formulation : Water(~100%), Surfactants(100ppm), CNT(10ppm)

droplet pitch : 50 μ m, 3 times overcoats

TFT characteristics : on/off ratio = 4000

mobility = 0.8cm²/Vs

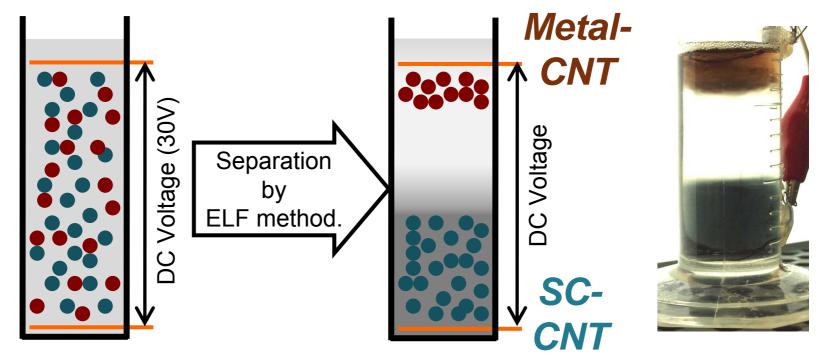
→ For more high mobility, we developed CNT Metal Semiconductor separation technology.



CNT Metal-Semiconducor separation technology

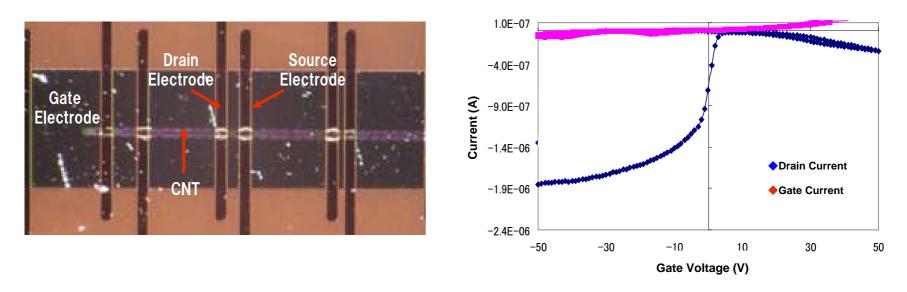
As for synthesized CNT, Semiconductor : Metal = 2:1 We developed an original separation technology to get better

- semiconductor sample. (Electric-field inducing Layer Formation)
 - Simple apparatus and Easy purification protocol
 - Applicable for wide diameter range (1.0-2.2 nm)
 - Ion-free process



We successfully obtained high purity semiconductor CNT.

CNT-TFT using high-purity semiconductive-CNT



ink formulation : Water(~100%), Surfactants(100ppm), CNT(10ppm) droplet pitch : 50μ m, 3 times overcoats TFT characteristics : on/off ratio = 9700 mobility = $5.1 \text{ cm}^2/\text{Vs}$ Improvement of both mobility and on-off ratio were achieved.

Summary

Carbon Nanotubes as Printed Electronic Materials
 Large carrier mobility

 → expect for high performance TFT

 Chemical and mechanical stability

 → suitable for ink manufacturing

Printed CNT Transistors
 CNT-TFT using high purity CNT and water-based ink mobility = 5.1cm²/Vs and on/off ratio = 10000
 Spreads decrease dramatically.

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